PTO/SB/08A	Complete if Known	
INFORMATION DISCLOSURE	Application Number	10/039,196
STATEMENT BY APPLICANT	Filing Date	January 2, 2002
(use as many sheets aspeces sary)	Confirmation Number	7221
(0)	First Named Inventor	Robert J. Falster
(NAS 0 8 SOUT)	Group Art Unit	1765
CATEN OF WEEK	Examiner Name	
Sheet 1 of 2	Attorney Docket No.	MEMC 00-1400 (2806.1)

		U.S.	PATEN	T DOCUMENTS	
		U.S. Patent Document			
Examiner Initials*	Cite No.1	Number	Kind Code ² (if known)	Name of Patentee or Applicant of Cited Document	Date of Publication of Cited Document MM-DD-YYYY
(DE	1	5,919,302		Falster et al.	07-06-1999
V	2	5,994,761		Falster et al.	11-30-1999
	3	6,180,220		Falster et al.	01-30-2001
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	5	6,254,672		Falster et al.	07-03-2001
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1	7	6,336,968		Falster	01-08-2002
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Examiner : Initials*	Cite No.	Include name of the author (in CAPITAL LETTERS), title of the article (when appropriate), title of the item (book, magazine, journal, serial, symposium, catalog, etc.) date, page(s), volume-issue number(s), publisher, city and/or country where published.			
B	8	R. FALSTER "The Phenomenology of Dielectric Breakdown in Thin Silicon Dioxide Films: Al Cathodes and p-type Si Anodes" J. Appl. Phys., Vol. 66, No. 7 (1989) pp. 3355-3370.			
76	9	R. FALSTER et al. "On the Properties of the Intrinsic Point Defects in Silicon: A Perspective from Crystal Growth and Wafer Processing" Phys. Stat. Sol. (b), Vol. 222, No. 1 (2000) pp. 219-244.			

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^{*}EXAMINER initial if reference considered, whether or not citation is in conformance with MPEP 609. Draw line through citation if not in conformance and not considered include copy of this form with next communication to applicant.

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Concue ditation designation number. "See attached kinds of U.S. Patent Documents." Enter Office that issued the document, by the two-letter code (W.P.C. Standard ST.3). "For Japanese patent documents, the indication of the year of the reign of the Emperor must precede the senal number of the patent document." Kind of document by the appropriate symbols as indicated on the document under M.P.O. Standard ST. 16 if possible. "Applicant is to place a check mark here if English language Translation's attached."

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(FAPR 0 8 2002 (2)	Examiner Name		
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		OTHER ART - NON PATENT LITERATURE DOCUMENTS		
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	11	A. VIRZI "Computer Modelling of Heat Transfer in Czochralski Silicon Crystal Growth" J. of Crystal Growth, Vol. 112, No. 4 (1991) pp. 699-722.		
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